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SHEET 1 OF 1

INFORMATION DISCLOSURE CITATION IN AN APPLICATION (PTO-1449)				ATTY. DOCKET NO. 60188-670	SERIAL NO. 10/676877	
				APPLICANT Taiji NODA		
				FILING DATE October 02, 2003	GROUP 2822	
U.S. PATENT DOCUMENTS						
EXAMINER'S INITIALS	CITE NO.	Document Number Number-Kind Code ₂ (<i>if known</i>)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	
<i>MJ</i>	B1	US 6,432,802	08/13/2002	Noda et al.		
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FOREIGN PATENT DOCUMENTS						
EXAMINER'S INITIALS	CITE NO.	Foreign Patent Document Country Codes-Number & Kind Codes (<i>if known</i>)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines Where Relevant Figures Appear	Translation
<i>MJ</i>		JP 8-250729	09/27/1996	ADVANCED MICRO DEVICES INC		Yes (Japan w/English Abstract) <input checked="" type="checkbox"/> No <input type="checkbox"/>
OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)						
EXAMINER'S INITIALS	CITE NO.	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.				
<i>MJ</i>		Noda et al., "Effects of end-of-range dislocation loops on transient enhanced diffusion of indium implanted in silicon", JOURNAL OF APPLIED PHYSICS, PP. 4980-4984, November 1, 2000.				
<i>MJ</i>		T. Noda, "Modeling of End-of-Range (EOR) Defects for Indium Channel Engineering", Tech. Dig. IEDM, p.839, 2001				
EXAMINER <i>Michael Trindl</i>			DATE CONSIDERED <i>5/23/05</i>			

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